REMARKS

Claims 1-11, 15-17, 30, 32-35, 37-44, 48-69, 73-80 and 83-85 now remain in this application. Claims 12-14, 18-29, 31, 36, 45-47, 70-72 and 81-82 have been withdrawn.

Claims 1--85 were subject to restriction and/or election requirement.

Election/Restrictions

The claims were held to be directed to the following four sets of species:

- A.) RF biasing techniques:
 - i) pulse modulation bias techniques;
 - ii) single burst bias;
- and B.) Workpiece or substrate or type of layer treated:
 - i) dielectric;
 - ii) semiconductor;
- and C.) Pre-treatments:
 - i) passivation of workpiece;
 - ii) "pre-cleaning" of workpiece;
 - iii) plasma cleaning chamber;
- and D.) Post-treatments:
 - i) thermal annealing;
 - ii) stripping photoresist or mask;
 - iii) wet-cleaning.

The applicants were required to elect a single disclosed species from each of the fours sets of species groups, i.e., one from each of Groups A, B, C and D, for prosecution.

Therefore, applicants hereby elect Species ii of Group A

(single burst bias), Species ii of Group B (semiconductor layer), Species i of Group C (passivation), and Species i of Group D (annealing). The claims reading on these elected species include Claims 1-11, 15-17, 30, 32-35, 37-44, 48-69, 73-80 and 83-85. Claims 12-14, 18-29, 31, 36, 45-47, 70-72 and 81-82 are withdrawn, for later consideration should a generic claim be allowed.

As for Group A, this election includes claims that read on a continuous RF bias. As for Group B, this election includes claims that read on implantation in a semiconductor material of a workpiece that also includes a dielectric layer or layers. As for Group C, the passivation referred in Claim 15) pertains to passivation of the chamber.

Respectfully submitted,

Dated: <u>MW. 21 7006</u>

Robert M. Wallace

Reg. No. 29,119

Customer No. 000044843
Attorney for Applicants

Robert M. Wallace Patent Counsel 2112 Eastman Avenue, Suite 102 Ventura, CA 93003 (805) 644-4035